UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/824,526	04/15/2004	Kenji Ikeda	Q80776	6591	
23373 SUGHRUE MI	7590 05/25/2007 ON PLLC		EXAMINER		
2100 PENNSYLVANIA AVENUE, N.W.			MARTIN, LAURA E		
SUITE 800 WASHINGTON, DC 20037		•	ART UNIT	PAPER NUMBER	
			2853		
			·		
		•	MAIL DATE	DELIVERY MODE	
			05/25/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Application No.	Applicant(s)			
Office Action Summary		10/824,526	IKEDA ET AL.			
		Examiner	Art Unit			
		Laura E. Martin	2853			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filled after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).						
Status						
 Responsive to communication(s) filed on <u>04 May 2007</u>. This action is FINAL. 2b) This action is non-final. Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i>, 1935 C.D. 11, 453 O.G. 213. 						
Dispositi	Disposition of Claims					
 4) Claim(s) 1-16 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 1-16 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement. 						
Application Papers						
 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. 						
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
2) Notice 3) Information	et(s) ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) can Disclosure Statement(s) (PTO/SB/08) can No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:	ate			

Office Action Summary

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yoshino et al. (US 5955185) in view of Takahashi (JP 2003-073598) and Nojima et al. (US 6620470).

Yoshino et al. disclose the following claim limitations:

As per claim 1: an ink jet recording medium comprising a support (figure 1, element 3) and a colorant receiving layer (figure 1, element 2) provided on the support and having a porous structure containing at least polymer fine particles (column 1, lines 15-34); a void volume per unit thickness (A/B) of the colorant receiving layer calculated by dividing a void volume A (x10⁵ ml/cm²) of the colorant receiving layer at a void diameter equal to a particle size of the polymer fine particles obtained from a pore distribution curve by a nitrogen gas adsorption method, by a dry layer thickness B (micrometers).

As per claim 4: an ink jet recording method according to claim 1, wherein the void volume A of the colorant receiving layer at the same void diameter as the particle size of the polymer fine particles is 50×10^{-5} ml/cm²) or more (column 8, lines 5-10).

As per claim 5: an ink jet recording method, wherein a ratio [(Y/X)x100] of a void diameter Y (nm) corresponding to a maximum peak of the void volume of the colorant receiving layer obtained from a pore distribution curve by a nitrogen gas adsorption method, to the particle size X (nm) of the polymer fine particles is 65% or more (column 8, lines 29-35).

As per claims 6-10: an ink jet recording method wherein the porous structure of the colorant receiving layer is formed of secondary particles of the polymer fine particles (see examples; column 25, line 45-column 26, line 67).

As per claims 11-15: an ink jet recording method according to claim 6, wherein a void diameter Y corresponding to a maximum peak of a void volume formed by the secondary particles of polymer fine particles of the colorant receiving layer obtained from a pore distribution curve by a nitrogen gas adsorption method is 33 nm or more (column 7, lines 40-45).

Yoshino et al. do not disclose the following claim limitations:

As per claim 1: a method comprising utilizing an ink composition comprising a colored fine particle dispersion containing at least one kind of hydrophobic polymer and at least one kind of organic solvent having a high boiling point; a porous structure containing at least organic polymer fine particles; and the void volume per unit thickness is 3.0 to 5.0 (x 10⁻⁵ ml/cm²/micrometers) or more.

As per claim 2: the hydrophobic dye contains at least one kind of compound selected from the group consisting of compounds represented by the following general formula (I), compounds represented by the following general formula (II), compounds represented by the following general formula (Y-I), compounds represented by the following general formula (M-I) and compounds represented by the following general formula (C-I)

General formula (I)

$$Y = N = N$$

$$R^{2}$$

$$R^{4}$$

$$R^{4}$$

$$R^{4}$$

$$R^{4}$$

$$R^{2}$$

$$R^{4}$$

$$R^{2}$$

$$R^{3}$$

$$R^{4}$$

$$R^{2}$$

$$R^{4}$$

$$R^{4}$$

$$R^{2}$$

$$R^{4}$$

$$R^{4}$$

$$R^{4}$$

$$R^{4}$$

$$R^{5}$$

$$R^{4}$$

$$R^{5}$$

$$R^{4}$$

$$R^{5}$$

$$R^{5}$$

$$R^{7}$$

$$R^{$$

wherein, in General formula (I) and General formula (II), R¹, R², R³, and R⁴ each independently represent a hydrogen atom, halogen atom, aliphatic group, aromatic group, heterocyclic group, cyano group, hydroxy group, nitro group, amino group, alkylamino group, alkoxy group, aryloxy group, amide group, arylamino group, ureide group, sulfamoylamino group, alkylthio group, arylthio group, alkoxycarbonylamino group, sulfoneamide group, carbamoyl group, sulfamoyl group, sulfonyl group, alkoxycarbonyl group, heterocyclic oxy group, azo group, acyloxy group, carbamoyloxy group, silyloxy group, aryloxycarbonyl group, aryloxycarbonylamino group, imide group, heterocyclic thio group, sulfinyl group, phosphoryl group, acyl group, carboxyl group, or sulfo group; A represents --NR⁵R⁶ or a hydroxyl group; R⁵ and R⁶ each independently

represent a hydrogen atom, aliphatic group, aromatic group or heterocyclic group; R⁵ and R⁶ may mutually bond to form a ring; B¹ represents = C(R³)- or = N-; B² represents -C(R⁴)= or -N=; and R¹ and R⁵, R³ and R⁶ may mutually bond to form an aromatic ring or heterocyclic ring, and/or R¹ and R² may mutually bond to form an aromatic ring or heterocyclic ring, General formula (Y-I)

A-N=N-B

wherein, in General formula (Y-I), A and B each independently represent an optionally substituted heterocyclic group,

$$A = N = N$$

$$R^{2} = R^{1}$$

$$R^{5}$$

$$R^{6}$$

$$R^{6}$$

Wherein, in General formula (M-I), A represents a moiety of a 5-membered heterocyclic diazo component (A-NH₂); B¹ represents = CR¹- and B² represents -CR²=. or alternatively one of B¹ and B² represents a nitrogen atom and the other represents =CR¹- or -CR²=: R¹ and R⁶ each independently represent a hydrogen atom, aliphatic group, aromatic group, heterocyclic group, acyl group, alkoxycarbonyl group, aryloxycarbonyl group, carbamoyl group, alkylsulfonyl group, arylsulfonyl group or sulfamoyl group, each of which may further have a substituent; G, R¹ and R² each independently represent a hydrogen atom, halogen atom, aliphatic group, aromatic group, heterocyclic group, cyano group, carboxyl group, carbamoyl group. alkoxycarbonyl group, aryloxycarbonyl group, acyl group, hydroxyl group, alkoxy group,

aryloxy group, silyloxy group, acyloxy group, carbamoyloxyl group, heterocyclic oxy group, alkoxycarbonyloxy group, aryloxycarbonyloxy group, amino group substituted with an alkyl group, aryl group or heterocyclic group, acylamino group, ureide group, sulfamoylamino group, alkoxycarbonylamino group, aryloxycarbonylamino group, alkylarylsulfonylamino group, arylsulfonylamino group, aryloxycarbonylamino group, nitro group, alkylthio group, arylthio group, alkylsulfonyl group, arylsulfonyl group, alkylsulfinyl group, arylsulfinyl group, sulfamoyl group, sulfo group, or heterocyclic thio group, each of which may further be substituted; and R1 and R⁵, or R⁵ and R⁶ may bond to form a 5 or 6-membered ring,

$$(X^{1})_{54}$$

$$(X^{2})_{10}$$

$$(X^{2})_{10}$$

$$(X^{2})_{10}$$

$$(X^{2})_{10}$$

$$(X^{2})_{10}$$

$$(X^{2})_{10}$$

$$(X^{2})_{10}$$

Wherein, in General formula (C-I) X¹, X², X³ and X⁴ each independently represent -SO-Z¹, -SO²-Z¹ or -SO²NR²¹R²²; Z¹ represents a substituted or unsubstituted alkyl group, substituted or unsubstituted cycloalkyl group, substituted or unsubstituted alkenyl group, substituted or unsubstituted aralkyl group, substituted or unsubstituted aryl group, or substituted or unsubstituted heterocyclic group; R²¹ and R²² each

independently represent a hydrogen atom, substituted or unsubstituted alkyl group, substituted or unsubstituted cycloalkyl group, substituted or unsubstituted alkenyl group, substituted or unsubstituted aralkyl group, substituted or unsubstituted aryl group, or substituted or unsubstituted heterocyclic group; Y¹, Y², Y³ and Y⁴ each independently represent a hydrogen atom, halogen atom, alkyl group, cycloalkyl group, alkenyl group, aralkyl group, aryl group, heterocyclic group, cyano group, hydroxyl group, nitro group, amino group, alkylamino group, alkoxy group, aryloxy group, amide group, arylamino group, ureide group, sulfamoylamino group, alkylthio group, arylthio group, alkoxycarbonylamino group, sulfoneamide group, carbamoyl group, sulfamoyl group, sulfonyl group, alkoxycarbonyl group, heterocyclic oxy group, azo group, acyloxy group, carbamoyloxyl group, silyloxy group, aryloxycarbonyl group, aryloxycarbonylamino group, imide group, heterocylic thio group, phosphoryl group, acyl group, carbonyl group, or sulfo group, each of which may further have a substituent; a¹ to a⁴ and b¹ to b⁴ represent the numbers of substituents X¹ to X⁴ and Y¹ to Y⁴, respectively; a¹ to a⁴ each independently represent an integer of 0 to 4; b¹ to b⁴ each independently represent an integer of 0 to 4; the sum of a¹ to a⁴ is 2 or more; when any one of a¹ to a⁴ and b¹ to b⁴ represent an integer of 2 or more, a corresponding plurality of any one X¹ to X⁴ and Y¹ to Y⁴ may be the same or different; a.sup.1 and b.sup.1 each independently represent an integer of 0 to 4 satisfying the relation of a¹+b¹=4; a² and b² each independently represent an integer of 0 to 4 satisfying the relation of $a^2 + b^2 = 4$: a^3 and b^3 each independently represent an integer of 0 to 4 satisfying the relation of $a^3 + b^3 = 4$; a^4 and

b⁴ each independently represent an integer of 0 to 4 satisfying the relation of a a⁴ + b⁴
=4; and M represents a hydrogen atom, metal element or its oxide, hydroxide, or halide.

As per claim 3: the organic solvent having a high boiling point is an organic solvent having a water solubility of 4 g or less.

Takahashi et al. disclose the following claim limitations:

As per claim 1: a colored fine particle dispersion containing at least one kind of hydrophobic dye, at least one kind of hydrophobic polymer and at least one kind of organic solvent having a high boiling point [0009],

As per claim 2: the hydrophobic dye contains at least one kind of compound selected from the group consisting of compounds represented by the following general formula (I), compounds represented by the following general formula (II), compounds represented by the following general formula (Y-I), compounds represented by the following general formula (M-I) and compounds represented by the following general formula (C-I) [0010]

wherein, in General formula (I) and General formula (II), R¹, R², R³, and R⁴ each independently represent a hydrogen atom, halogen atom, aliphatic group, aromatic group, heterocyclic group, cyano group, hydroxy group, nitro group, amino group, alkylamino group, alkoxy group, aryloxy group, amide group, arylamino group, ureide group, sulfamoylamino group, alkylthio group, arylthio group, alkoxycarbonylamino group, sulfoneamide group, carbamoyl group, sulfamoyl group, sulfonyl group, alkoxycarbonyl group, heterocyclic oxy group, azo group, acyloxy group, carbamoyloxy group, silyloxy group, aryloxycarbonyl group, aryloxycarbonylamino group, imide group, heterocyclic thio group, sulfinyl group, phosphoryl group, acyl group, carboxyl group, or sulfo group; A represents --NR⁵R⁶ or a hydroxyl group; R⁵ and R⁶ each independently represent a hydrogen atom, aliphatic group, aromatic group or heterocyclic group; R⁵ and R⁶ may mutually bond to form a ring; B¹ represents =C(R³)- or =N-; B² represents -C(R⁴)= or -N=; and R¹ and R⁵, R³ and R⁶ may mutually bond to form an aromatic ring or heterocyclic ring, and/or R¹ and R² may mutually bond to form an aromatic ring or heterocyclic ring, General formula (Y-I)

A-N=N-B

wherein, in General formula (Y-I), A and B each independently represent an optionally substituted heterocyclic group,

Application/Control Number: 10/824,526 Page 10

Art Unit: 2853

Wherein, in General formula (M-I), A represents a moiety of a 5-membered heterocyclic diazo component (A-NH₂); B¹ represents = CR¹- and B² represents -CR²=. or alternatively one of B¹ and B² represents a nitrogen atom and the other represents =CR¹- or -CR²=: R¹ and R⁶ each independently represent a hydrogen atom, aliphatic group, aromatic group, heterocyclic group, acyl group, alkoxycarbonyl group, aryloxycarbonyl group, carbamoyl group, alkylsulfonyl group, arylsulfonyl group or sulfamoyl group, each of which may further have a substituent; G, R¹ and R² each independently represent a hydrogen atom, halogen atom, aliphatic group, aromatic group, heterocyclic group, cyano group, carboxyl group, carbamoyl group, alkoxycarbonyl group, aryloxycarbonyl group, acyl group, hydroxyl group, alkoxy group, aryloxy group, silyloxy group, acyloxy group, carbamoyloxyl group, heterocyclic oxy group, alkoxycarbonyloxy group, aryloxycarbonyloxy group, amino group substituted with an alkyl group, aryl group or heterocyclic group, acylamino group, ureide group, sulfamoylamino group, alkoxycarbonylamino group, aryloxycarbonylamino group, alkylarylsulfonylamino group, arylsulfonylamino group, aryloxycarbonylamino group, nitro group, alkylthio group, arylthio group, alkylsulfonyl group, arylsulfonyl group, alkylsulfinyl group, arylsulfinyl group, sulfamoyl group, sulfo group, or heterocyclic thio group, each of which may further be substituted; and R1 and R5, or R5 and R6 may bond to form a 5 or 6-membered ring,

Application/Control Number: 10/824,526

Art Unit: 2853

$$(X^{2})_{04}$$

$$(X^{2})_{04}$$

$$(X^{2})_{04}$$

$$(X^{2})_{04}$$

$$(X^{2})_{04}$$

$$(X^{2})_{04}$$

$$(X^{2})_{04}$$

$$(X^{2})_{04}$$

$$(X^{2})_{04}$$

Wherein, in General formula (C-I) X¹, X², X³ and X⁴ each independently represent -SO-Z¹, -SO²-Z¹ or -SO²NR²¹R²²; Z¹ represents a substituted or unsubstituted alkyl group, substituted or unsubstituted cycloalkyl group, substituted or unsubstituted alkenyl group, substituted or unsubstituted aralkyl group, substituted or unsubstituted aryl group, or substituted or unsubstituted heterocyclic group; R²¹ and R²² each independently represent a hydrogen atom, substituted or unsubstituted alkyl group, substituted or unsubstituted alkenyl group, substituted or unsubstituted aralkyl group, substituted or unsubstituted aryl group, or substituted or unsubstituted aralkyl group, substituted or unsubstituted aryl group, or substituted or unsubstituted heterocyclic group; Y¹, Y², Y³ and Y⁴ each independently represent a hydrogen atom, halogen atom, alkyl group, cycloalkyl group, alkenyl group, aralkyl group, aryl group, heterocyclic group, cyano group, hydroxyl group, nitro group, amino group, alkylamino group, alkoxy group, aryloxy group, amide group, arylamino group, ureide group, sulfamoylamino group, alkylthio group, sulfamoyl group, alkoxycarbonylamino group, sulfoneamide group, carbamoyl group, sulfamoyl group,

sulfonyl group, alkoxycarbonyl group, heterocyclic oxy group, azo group, acyloxy group, carbamoyloxyl group, silyloxy group, aryloxycarbonyl group, aryloxycarbonylamino group, imide group, heterocylic thio group, phosphoryl group, acyl group, carbonyl group, or sulfo group, each of which may further have a substituent; a¹ to a⁴ and b¹ to b⁴ represent the numbers of substituents X¹ to X⁴ and Y¹ to Y⁴, respectively; a¹ to a⁴ each independently represent an integer of 0 to 4; b¹ to b⁴ each independently represent an integer of 0 to 4; the sum of a¹ to a⁴ is 2 or more; when any one of a¹ to a⁴ and b¹ to b⁴ represent an integer of 2 or more, a corresponding plurality of any one X¹ to X⁴ and Y¹ to Y⁴ may be the same or different; a.sup.1 and b.sup.1 each independently represent an integer of 0 to 4 satisfying the relation of a¹+b¹=4; a² and b² each independently represent an integer of 0 to 4 satisfying the relation of $a^2 + b^2 = 4$; a^3 and b^3 each independently represent an integer of 0 to 4 satisfying the relation of a³ + b³ =4; a⁴ and b⁴ each independently represent an integer of 0 to 4 satisfying the relation of a a⁴ + b⁴ =4; and M represents a hydrogen atom, metal element or its oxide, hydroxide, or halide [0011-0017].

As per claim 3: the organic solvent having a high boiling point is an organic solvent having a water solubility of 4 g or less [0009].

It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the method taught by Yoshino et al. with the disclosure of Takahasi et al. in order to create a high quality image using ink and medium.

Nojima et al. disclose the following claim limitations:

Application/Control Number: 10/824,526 Page 13

Art Unit: 2853

As per claim 1: a porous structure containing at least organic polymer fine

particles (column 22, lines 1-10) and the void volume per unit thickness is 3.0 to 5.0 (x

10⁻⁵ ml/cm²/micrometers) or more (column 11, line 65-column 12, line 7).

It would have been obvious to one of ordinary skill in the art at the time of the

invention to modify the method taught by Yoshino et al. with the disclosure of Nojima et

al. in order to provide high ink absorption and a high surface smoothness.

Claim 16 is rejected under 35 U.S.C. 103(a) as being unpatentable over Yoshino

et al. (US 5955185), Takahashi (JP 2003-073598) and Nojima et al. (US 6620470), and

further in view of Terase et al. (US 20020174805).

Yoshino et al. as modified discloses the method of claim 1; however, it does not

disclose the organic polymer fine particles are a copolymer of a vinyl monomer, an

ester-based polymer, a urethane based polymer, an amide based polymer, an epoxy

based polymer, or modified materials or copolymers thereof.

Terase et al. discloses organic polymer fine particles are a copolymer of a vinyl

monomer, an ester-based polymer, a urethane based polymer, an amide based

polymer, an epoxy based polymer, or modified materials or copolymers thereof [0058].

It would have been obvious to one of ordinary skill in the art at the time of the

invention to modify the method taught by Yoshino et al. as modified with the disclosure

of Terase et al. in order to provide a higher quality ink.

Response to Arguments

Application/Control Number: 10/824,526 Page 14

Art Unit: 2853

Applicant's arguments with respect to claims 1-16 have been considered but are most in view of the new ground(s) of rejection.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Laura E. Martin whose telephone number is (571) 272-2160. The examiner can normally be reached on Monday - Friday, 7:00 - 3:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Stephen D. Meier can be reached on (571) 272-2149. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Laura E. Martin

MANISH S. SHAH